CLAIMS

1. A polishing cloth comprising, as forming materials of the polishing cloth, an unwoven fabric and a resin that is impregnated in the unwoven fabric, wherein

an apparent density is in a range of 0.30 g/cm^3 to 0.50 g/cm^3, and

a standard deviation of an abundance ratio of the forming materials is 21.7% or less.

2. The polishing cloth according to claim 1, having a compression ratio of 5% or less.

3. The polishing cloth according to claim 1 or 2, wherein

a mean value of the abundance ratio of the forming materials is in a range of 22% to 45%.

4. The polishing cloth according to any one of claims 1 to 3, having an air pressure resistance of 23mmH_2O or more.